Nuclear, Plasma, and Radiological Engineering

NPRE 429  **Plasma Engineering**  credit: 3 hours.
Basic principles and examples for adapting and applying the plasma state to solve a number of modern engineering problems. Plasma processing of materials for microelectronics and other uses, lighting, plasma displays, and other technologies. 3 undergraduate hours. 3 graduate hours. Prerequisite: ECE 329 or PHYS 435.

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<td>39438</td>
<td>Lecture-Discussion</td>
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<td>02:00 PM - 02:50 PM</td>
<td>MWF</td>
<td>104 - Talbot Laboratory</td>
<td>Allain, J</td>
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